Notice of Draft Groundwater Withdrawal Permit –
GAF Materials Corporation – August 14, 2020

The Georgia Environmental Protection Division (EPD) announces its intent to issue a Modified Groundwater Withdrawal Permit No. 025-0013 for water withdrawal of 0.450 MGD/0.202 MGD (Monthly Average/Annual Average in million gallons per day) from one well in the Upper Floridan aquifer for the purpose of a central water supply, sanitary facilities, cooling water, process water for asphaltic roofing manufacturing, and fire protection. The permit modification changes the consumptive use listed on the current permit, removing reference to the dry felt machine that is no longer in use, and adding process water for asphaltic roofing manufacturing as a consumptive use. The current permit limits and permit limit reduction schedule will remain unchanged.

MODIFIED GROUNDWATER WITHDRAWAL PERMIT

Permittee's Name: GAF Materials Corporation

Permittee's Address: Savannah, GA 31408

River Basin: Savannah

Comment Period Expires: September 14, 2020

Additional Information: The draft permit and all information used to develop the draft permit are available for review. The information includes the application and all relevant supporting materials available to the permitting authority used in the permit review process. This information is available for review at the office of the Watershed Protection Branch, 2 Martin Luther King Jr. Dr., S.E., East Floyd Towers, Suite 1152, Atlanta, Georgia 30334. All comments received prior to or on the comment period expiration date above will be considered in the formulation of final determinations regarding the permit.

Persons wishing to comment on the draft Permit are required to submit their comments, in writing, to:

Bill Frechette, Unit Manager
Water Supply Program – Groundwater Withdrawal Unit
2 Martin Luther King Jr. Dr., S.E.
East Floyd Towers, Suite 1362
Atlanta, Georgia 30334

A public hearing may be held if the Director of the EPD finds a significant degree of public interest in a draft permit.